



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q63941

Kenichiro SATO, et al.

Appln. No.: 09/834,639

Group Art Unit: 1752

Confirmation No.: 3676

Examiner: Yvette M. Clarke

Filed: April 16, 2001

For: POSITIVE PHOTORESIST COMPOSITION

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TC 1700

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AMENDMENT UNDER 37 C.F.R. §1.111

Commissioner for Patents  
Washington, D.C. 20231

Sir:

This Amendment is submitted in response to the Office Action dated October 18, 2002. A Petition for a one-month extension of time is being concurrently filed, making a response due on or before February 19, 2003 (the U.S. Federal Government being closed on February 18, 2003). Please amend the above-identified application as follows:

IN THE SPECIFICATION:

Please delete the second paragraph on page 60 (delete Formula 10).

IN THE CLAIMS:

Please enter the following amended claims <sup>4</sup>1, 12 and 18:

4 (amended). A positive photoresist composition comprising:

02/20/2003 HLE333

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02 FC:1202

36.00 OP